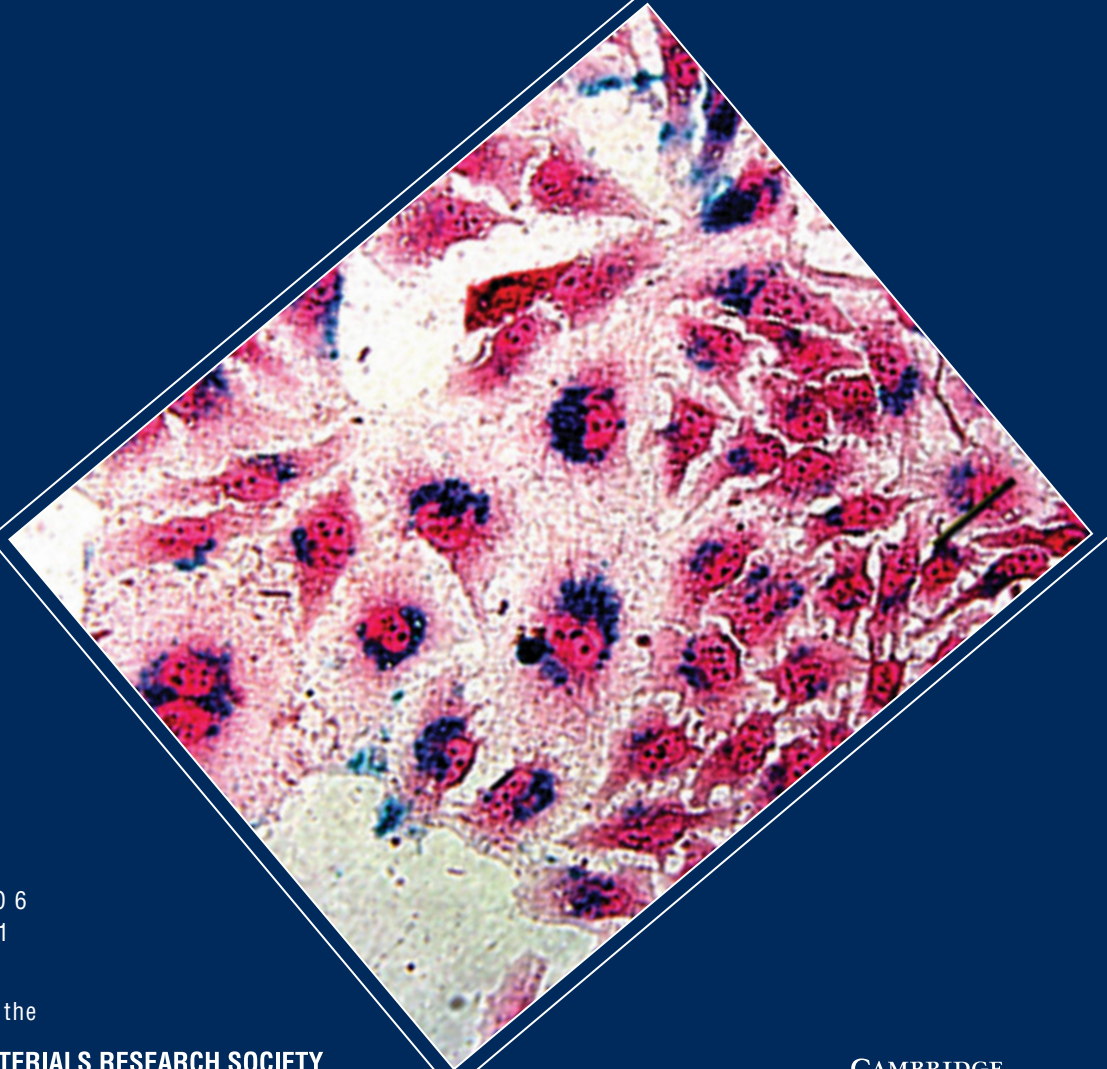




Journal of  
MATERIALS RESEARCH



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Cover: Prussian blue staining of HeLa cells treated with DMSA-coated Fe<sub>3</sub>O<sub>4</sub> magnetic nanoparticles at the concentration of 100 µg/mL for 48 h. Scale bar = 2 µm. [Y. Liu and J. Wang: Comparative and quantitative investigation of cell labeling of a 12-nm DMSA-coated Fe<sub>3</sub>O<sub>4</sub> magnetic nanoparticle with multiple mammalian cell lines. p. 822.]

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